## Application/Control No. O9/937,149 Examiner Kallambella Vijayakumar Applicant(s)/Patent Under Reexamination KOHIKI ET AL. Page 1 of 1

## **U.S. PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-			
	В	US-			
	C	US-			
	D	US-			
	Е	US-			
	F	US-			
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	Н	US-			
	l	US-			
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	К	US-			
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	М	US-			

## **FOREIGN PATENT DOCUMENTS**

	TORCION TATEM BOOMENTO							
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## **NON-PATENT DOCUMENTS**

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	U	Kohiki et al, " Enhanced Conductivity of Zinc Oxide thin films by ion implantation of hydrogen atoms", Appl. Phys. Lett. 1994, Vol. 64, Pp 2876-2878.			
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•	w	Ryuta et al, "Preparation and characterization of In2O3:Lix(x=0-1.0)", Nippon Kagaku Kaishi 1999, Volume-5, pp 323-327.			
	х	Sasaki et al, "Preparation and characterization of Lithium doped Indium Sesqui Oxide", J. Alloys and Compounds, 2001, 322, p 220-225.			

\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).) Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.